

## PAPER

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## 3D fluorescence confocal microscopy of InGaN/GaN multiple quantum well nanorods from a light absorption perspective†

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A nanostructure of In<sub>0.18</sub>Ga<sub>0.82</sub>N/GaN multiple quantum well (MQW) nanorods (NRs) was fabricated using top-down etching with self-organized nickel (Ni) nanoparticles as masks on the wafer. The optical properties of In<sub>0.18</sub>Ga<sub>0.82</sub>N/GaN MQW NRs were discussed by experiment and theory from a light absorption perspective. Three-dimensional (3D) optical images of NRs were successfully obtained by confocal laser scanning microscopy (CLSM) for physical observation of the optical phenomenon of InGaN/GaN MQW NRs. Moreover, optical simulations were performed by COMSOL Multiphysics via the three-dimensional finite-element method to explore the influences of NR geometrical parameters on optical absorption. The simulated results demonstrate that the absorption of NRs is higher than that of the film due to the waveguide properties of NRs resulting from their higher refractive index than embedding medium and higher aspect ratio than bulk. In addition, an increase in the diameter results in a red-shift of the absorption peak position of In<sub>0.18</sub>Ga<sub>0.82</sub>N/GaN MQW NRs. The smaller pitch enhances the near-field coupling of the nanorods and broadens the absorption peak. These results clearly illustrate the optical properties of In<sub>0.18</sub>Ga<sub>0.82</sub>N/GaN MQW NRs from the perspective of 3D confocal laser scanning microscopy. This work is promising for the applications of III–V optoelectronic devices.

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## Introduction

III–V semiconductor materials have excellent electrical and optical properties, such as direct band gap, high electron mobility and low effective mass.<sup>1–4</sup> Therefore, in recent years, III–V nanostructures have attracted enormous interest due to their potentially significant applications in photovoltaics, photodetection, waveguide devices, and biosensing.<sup>5–10</sup> In particular, the operating wavelengths of various devices constructed of III-nitride semiconductor materials cover the spectral range from near-infrared (NIR) to deep-ultraviolet (UV) spectrum because the bandgap can be adjusted in the range of 0.7–6.2 eV.<sup>4</sup> InGaN/GaN multiple quantum wells (MQWs) have been viewed as the most promising active regions for the applications of light-emitting optical devices in the UV-NIR spectrum.<sup>11–13</sup> Besides, InGaN/GaN MQW nanorods (NRs) can overcome the

negative impacts of dislocations caused by large lattice mismatch.<sup>14–16</sup> Therefore, high crystalline quality with nanostructured InGaN/GaN MQWs can be acquired to improve the light extraction efficiency and achieve efficient light absorption. Considering the controllability of the size and density of nickel (Ni) nanoparticles, self-organized Ni nanoparticles can be used as etching masks by rapid thermal annealing (RTA). As a result, the nanorods fabricated by the top-down etching method provide a feasible choice for the synthesis of nanorods.<sup>17–19</sup> Furthermore, the special properties of nanostructures that carriers and photons are confined in the transverse directions and propagate freely in longitudinal direction<sup>20,21</sup> can produce special optical phenomena. In addition, some reports<sup>22,23</sup> on 3D PL imaging of the In<sub>0.18</sub>Ga<sub>0.82</sub>N/GaN MQW NRs are helpful for understanding the optical properties. In order to study the optical phenomena of nanorods, confocal laser scanning microscopy (CLSM) can be used to perform 3D scanning to understand the interaction between light and nanostructures. 3D imaging of nanostructures in a microscopic environment using confocal scanning microscopes<sup>24</sup> has been extensively reported.

The optical properties of nanostructured devices are not only affected by the complex refractive index of the material, but also by the geometry and size of the nanostructure.<sup>25–27</sup> Previously, many theoretical reports have studied the light absorption and waveguide properties of nanostructured arrays.<sup>20,28–33</sup> Other

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reported experiments<sup>20,21,31,33,34</sup> also reveal that the absorption of nanostructure arrays is strongly influenced by geometrical parameters, which agrees well with the simulation results. These results<sup>28,29,32,35</sup> illustrated that the absorptance of nanostructures is larger than that of thin-film materials. However, how light interacts with InGaN/GaN MQW NRs still needs to be explored, which will play an important role in future optoelectronic devices like nanorod solar cells and photodetectors. Particularly, InGaN/GaN MQW NRs can offer useful spectral regions for UV-NIR photodetectors in light detection and ranging systems due to the large band gap tunability from 0.7 to 3.4 eV. Apart from that, it can achieve broadband absorption of III-V semiconductor NR arrays for photovoltaic applications.

In this work, the optical properties of InGaN/GaN MQW NRs on a sapphire substrate are investigated by combining experimental and theoretical approaches. The InGaN/GaN MQW NRs were fabricated by the top-down etching approach with self-organized Ni nano-island masks on the MQW wafer. The characterizations of the InGaN/GaN MQW NRs were carried out by atomic force microscopy (AFM) and field emission scanning electron microscopy (FE-SEM). Moreover, 3D fluorescence confocal laser scanning microscopy was performed to analyze the optical properties of InGaN/GaN MQW NRs. The result demonstrates that the nanorod geometry parameters have an influence on its optical properties. On the other hand, theoretically, numerical simulations were carried out by COMSOL Multiphysics *via* the three-dimensional finite-element method to explore the optical absorptance of electromagnetic waves and light-matter interactions in the InGaN/GaN MQW NR arrays systematically. The results indicate that the optical absorption characteristics of InGaN/GaN MQW NRs are significantly affected by the nanorod geometry including diameter, pitch (spacing between NRs), and filling ratio, which coincides with the experimental results from 3D CLSM.

## Methods

The InGaN/GaN MQW NRs were fabricated by the top-down etching method on a planar InGaN/GaN MQW wafer, which was grown on a *c*-plane sapphire substrate by a metal-organic chemical vapor deposition (MOCVD) system. The group-III sources originated from trimethylgallium and trimethylindium, and the group-V source originated from NH<sub>3</sub>. The MOCVD-grown InGaN/GaN MQW structure was composed of a 20 nm-thick low temperature GaN buffer layer, a 2 μm-thick n-GaN epitaxial layer grown at 1050 °C, emitting layers with five

pairs of 4/10 nm-thick InGaN (well layer)/GaN (barrier layer) MQWs, and a 200 nm-thick GaN cap layer. It was similar to our previous report<sup>17</sup> that after the growth of planar InGaN/GaN MQW wafer, the InGaN/GaN MQW NRs were prepared by dry etching using Ni nanoparticles as a mask on the wafer. Firstly, a 5 nm Ni thin film was deposited on the surface of the planar MQW wafer by electron-beam (EB) evaporation. Then, in order to form self-organized Ni nanoparticles on the surface of the wafer sample, the Ni film was annealed at a temperature of 800 °C for 3 min by using the RTA process. InGaN/GaN MQW NRs can be fabricated by the dry etching method with the self-organized Ni nanoparticles used as an etching mask, which is attributed to the great selective etching rate of Ni for GaN-based materials.<sup>36</sup> An inductively coupled plasma-reactive ion etching (ICP-RIE) system with Cl<sub>2</sub> and BCl<sub>3</sub> etchant gases was employed to perform InGaN/GaN MQW etching. Finally, residual Ni nano-masks were removed by immersing the sample into dilute hydrochloric acid (HCl) solution. The schematic diagrams of the detailed fabrication processes for the InGaN/GaN MQW NRs are illustrated in Fig. 1.

AFM and FE-SEM (ZEISS SIGMA 04-03) were used to characterize the self-assembled Ni nanoparticles and morphologies of fabricated InGaN/GaN MQW NRs. The photoluminescence (PL) property of the MQWs NRs at room temperature was measured by an Invia micro-Raman system (Renishaw LabRAM) with a 325 nm He-Cd excitation laser. A confocal laser scanning microscope (Zeiss CLSM 710) was used to obtain 2D images of nanorod arrays by scanning the laser beam (405 nm excitation) in the *xy*-plane, and obtain 3D images by acquiring *z*-stacks of *xy*-plane images with a vertical distance of 100 nm between each image. The nanorod images were obtained by using a 63× oil-immersion objective of numerical aperture of NA = 1.4 and image analysis was performed using ZEN 2008 software.

Theoretically, in order to explore the optical absorption properties of the InGaN/GaN MQW NR arrays, numerical simulations were performed by COMSOL Multiphysics with the finite-element method. In the finite element simulation, a plane wave of 405 nm corresponding to the wavelength of the laser applied for the confocal experiment was used as the incident light on the top of the NRs, which was parallel to the NR axis (*z* direction). The absorptance (*A*) of the nanorod can be obtained by solving the Helmholtz equations in three-dimensional optical simulation. Furthermore, the absorptance *A*(λ) is given by the equation:

$$A(\lambda) = 1 - R(\lambda) - T(\lambda), \quad (1)$$

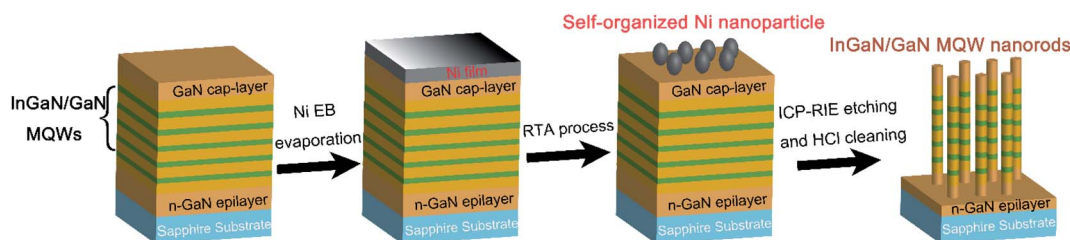


Fig. 1 Schematic diagrams of the fabrication process for InGaN/GaN MQW nanorods.



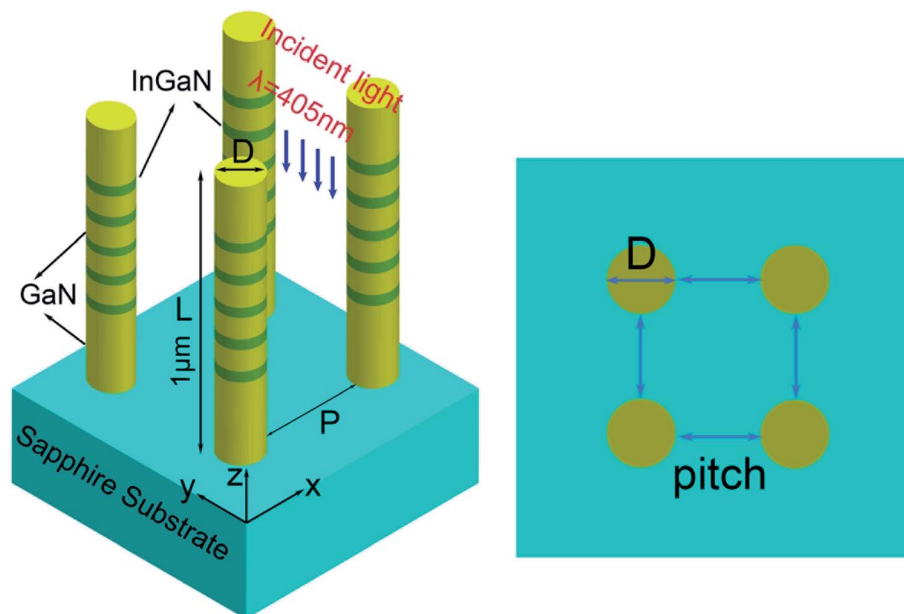


Fig. 2 Schematic drawing of the periodic InGaN/GaN MQW NR array on a sapphire substrate.

where  $R(\lambda)$  is the reflectance denoting the incident light from NRs back into air, and  $T(\lambda)$  is the transmittance representing light through the NR array into the substrate. The reflectance  $R(\lambda)$  and transmittance  $T(\lambda)$  are calculated by the Poynting vector, that is the energy flux density between the material interfaces.<sup>25,37</sup> It was found that the optical properties of the InGaN/GaN MQW NRs depend on the geometry according to the optical phenomenon from 3D fluorescence confocal

microscopy. Fig. 2 shows the schematic diagram of the InGaN/GaN MQW NRs arranged vertically. The square array surrounded by air is composed of five periods 4/10 nm-thick InGaN/GaN MQW NRs with diameter ( $D$ ) and length ( $L$ ) consistent with the nanorod structure parameters obtained in the experiment. Besides, the pitch is defined as the edge-to-edge distance of the NRs. To simplify the computational calculation, Floquet periodic boundary conditions were used to simulate

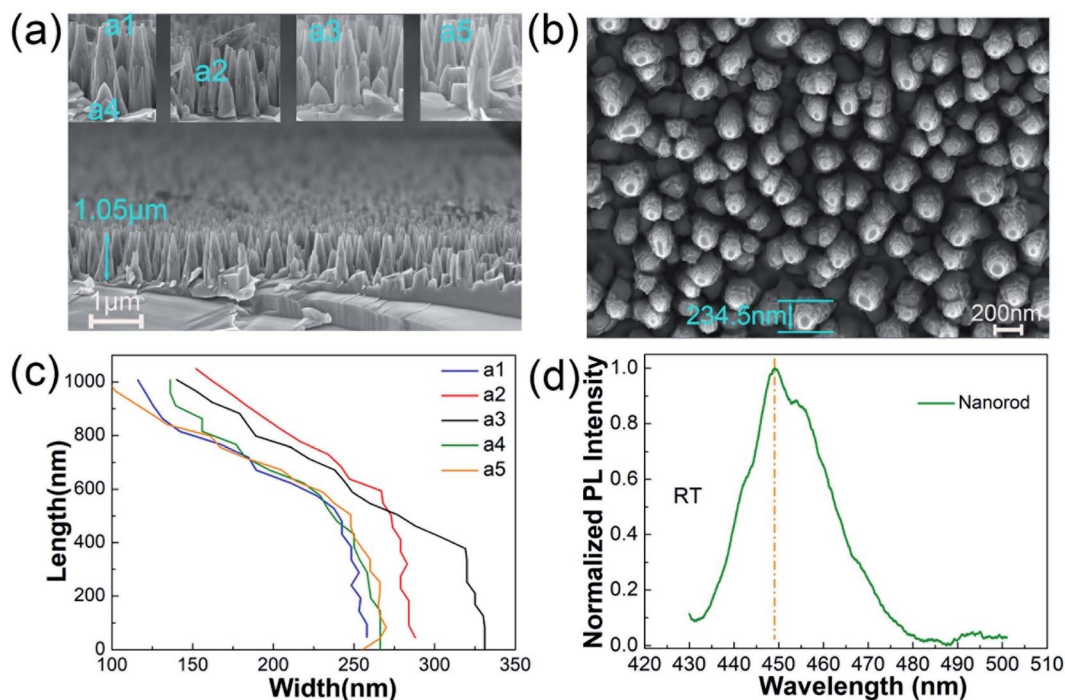


Fig. 3 (a) Cross-sectional-view and (b) top-view SEM image of InGaN/GaN MQW NRs after ICP etching. (c) Width varies with length of the NRs. (d) PL spectra of the fabricated MQW NRs at room temperature. The insets in (a) show SEM images of several representative NRs.





a periodic structure whose pitch ( $P$ ) was the same in the  $x$  and  $y$  direction. Perfectly matched layers (PMLs) were employed at the top and bottom of the nanorods to simulate the semi-infinite air and sapphire substrate. The finite nanorod length of  $1\ \mu\text{m}$  was achieved by introducing a finite-thickness sapphire substrate between the nanorod and the PML subdomain. The wavelength-dependent complex refractive index (real part  $n(\lambda)$  and imaginary part  $k(\lambda)$ ) used to describe the dispersion characteristics of InGaN/GaN materials is given in Fig. S1.<sup>†</sup>

## Results and discussion

Fig. 3(a) and (b) show the SEM images of fabricated  $\text{In}_{0.18}\text{Ga}_{0.82}\text{N}/\text{GaN}$  MQW NR arrays by ICP-RIE etching using self-organized Ni nano-island mask. It can be observed that the NRs reveal a vertical height of about  $1.05\ \mu\text{m}$  and a diameter width of  $235\ \text{nm}$ . In addition, several representative NRs have been chosen to study the variation of their width along the length of the NR and demonstrated that the size of these structures is below micrometers, which fit the “nano” criteria. Although the base is wider than the tip, the width is uniform at the distance is more than  $400\ \text{nm}$  from the top, so we approximate these structures as rods as a whole. Fig. 3(d) displays the normalized PL intensities of the InGaN/GaN MQW NRs at room temperature. The PL spectra exhibit an emission peak at about  $449\ \text{nm}$  ( $2.76\ \text{eV}$ ) with a full-width at half-maximum (FWHM) of about  $141\ \text{meV}$ . Since the fabricated nanorods are randomly distributed, the uniformity of the size of  $\text{In}_{0.18}\text{Ga}_{0.82}\text{N}/\text{GaN}$  MQW NRs and the effects on the optical properties for non-periodic NRs are discussed in Fig. S2 of ESI.<sup>†</sup> More details about the nanoscale self-assembly Ni islands by RTA at  $800\ ^\circ\text{C}$  for  $3\ \text{min}$  are shown in Fig. S3.<sup>†</sup>

Fig. 4 displays the confocal pictures of NRs in  $XY$ ,  $XZ$  and  $YZ$  planes at  $8\ \text{bit}$  resolution corresponding to the red lines on the  $XY$  image. It can be seen that the NRs can emit fluorescent light

under the excitation of a  $405\ \text{nm}$  laser. The pinhole was set to one Airy unit, thus, the optical lateral resolution is  $R_{xy} = 176.5\ \text{nm}$  and  $z$ -resolution is  $R_z = 289.3\ \text{nm}$ . In addition, according to the confocal 3D image of the nanorod arrays, NRs with different pitches exhibit different optical phenomena that the luminous intensity around the NRs with a small pitch is stronger than that with a large pitch. Thus, we design different periodic array structures according to the various pitches of NRs shown in Fig. 4(a). Two different magnifications can be found in Fig. S3 of ESI.<sup>†</sup>

Fig. 5(a) shows the calculated total absorption spectra  $A(\lambda)$  of the InGaN/GaN MQW NR arrays with  $L = 1\ \mu\text{m}$ ,  $D = 235\ \text{nm}$  and  $P = 100\ \text{nm}$  using a plane wave with a wavelength ranging from  $200\ \text{nm}$  to  $1000\ \text{nm}$ . The simulated result indicates that a broad absorption peak appears in the InGaN/GaN MQW NRs due to effective couple of the incident light into HE<sub>11</sub> and HE<sub>12</sub> optical resonance modes for a large diameter of  $235\ \text{nm}$ . Besides, when the wavelength is larger than  $440\ \text{nm}$ , the absorption begins to decrease owing to transmission and reflection losses. The electric field distribution diagrams at the resonant wavelengths ( $\lambda = 315$  and  $440\ \text{nm}$ ) and non-resonant wavelengths ( $\lambda = 550$  and  $700\ \text{nm}$ ) are plotted in Fig. 5(b)–(f). The electric field intensity at the resonance mode has a significant maximum along the length of the nanorod. In addition, a part of the electric field exists around the nanorod. Therefore, light can be absorbed in the NRs. The electric field for  $\lambda = 315\ \text{nm}$  shown in Fig. 5(b) is mainly localized on the top of the NRs and then decays rapidly, so that it cannot reach the bottom. On the other hand, the electric field for  $\lambda = 700\ \text{nm}$  shown in Fig. 5(f) is mainly in air and hardly localized inside the nanorod, resulting in extremely low absorption. It can also be seen from the modal electric field diagrams shown in the insets that the mode at resonance ( $\lambda = 315\ \text{nm}$ ) is confined to the nanorod, while the mode at non-resonance ( $\lambda = 700\ \text{nm}$ ) is mostly in air, indicating a better confinement at resonance. The top-view

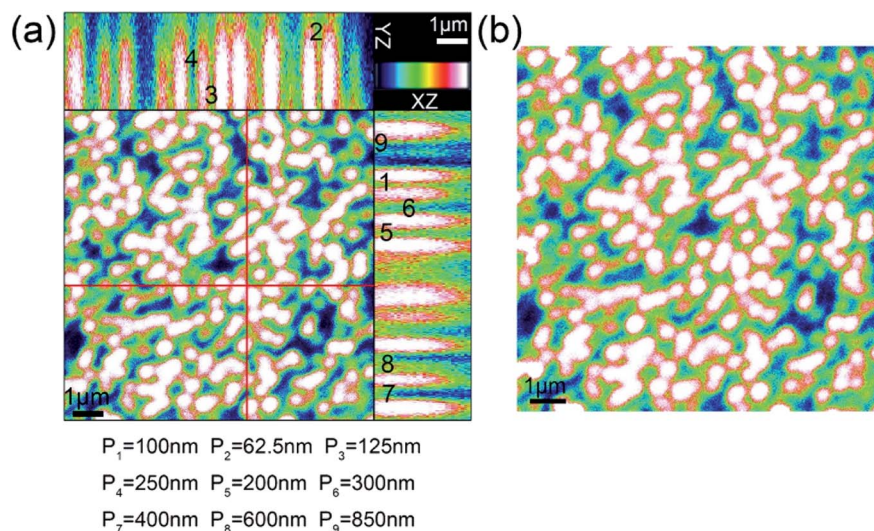
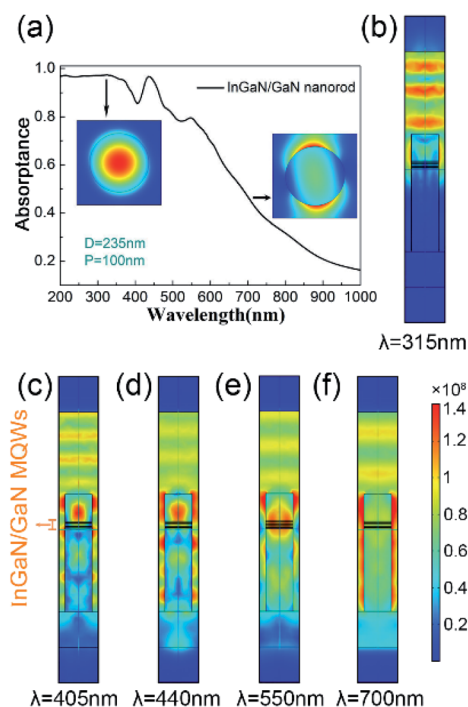


Fig. 4 (a) Confocal  $XZ$  and  $YZ$  cross-sectional images of nanorod arrays with  $d = 235\ \text{nm}$  and  $L = 1\ \mu\text{m}$  derived by  $100\ \text{nm}$   $z$ -stack in  $xy$ -plane. (b) Confocal  $xy$  slice of nanorods with different pitches excited by  $405\ \text{nm}$  laser.



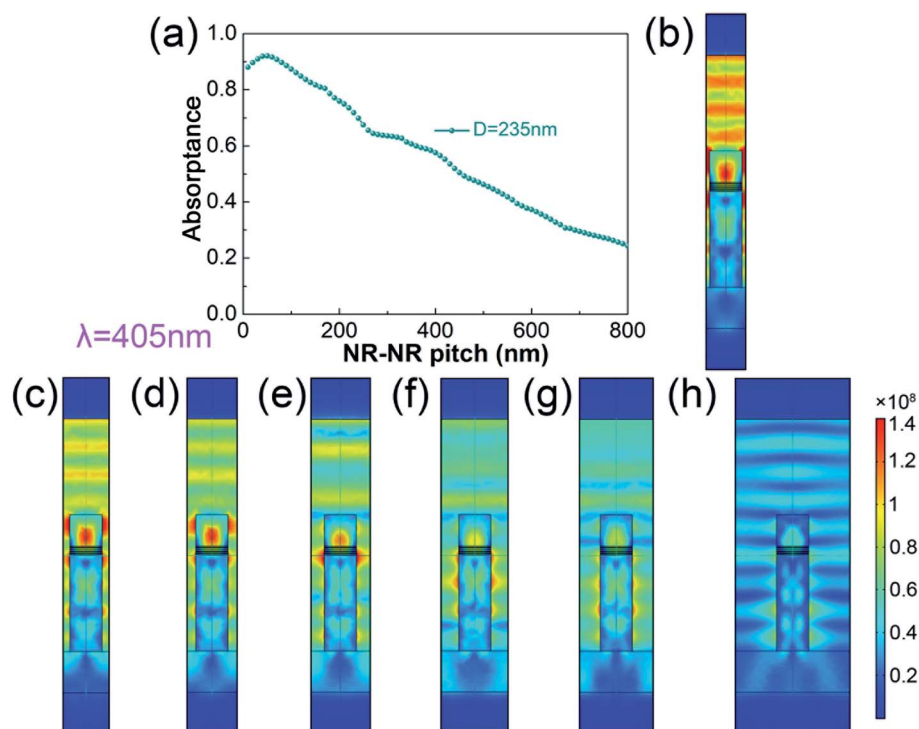


**Fig. 5** (a) Simulated total absorption spectra  $A(\lambda)$  of the vertical InGaN/GaN MQW NR arrays with  $L = 1 \mu\text{m}$ ,  $D = 235 \text{ nm}$ , and  $P = 100 \text{ nm}$ . (b)–(f)  $xz$ -Plane electric field intensity distributions within nanorods at the resonant wavelengths and non-resonant wavelengths. The inset shows the electric field distributions of the fundamental mode at two representative wavelengths.

electric field profiles at  $z = 120 \text{ nm}$  are depicted in Fig. S4 (see ESI†).

The dependence of the InGaN/GaN MQW NR absorption on the NR pitch is displayed in Fig. 6(a). It is found that the absorbance ( $\lambda = 405 \text{ nm}$ ) reaches a maximum value of 92.1% for the nanorod array with a pitch of 50 nm. Furthermore, the absorption declines as the pitch increases, which would be attributed to the reason that as the pitch increases, the fill factors decrease and the near-field coupling becomes weaker. The electric field distributions of the  $xz$ -plane are plotted in Fig. 6(b)–(h), in order to analyse the reason for the decrease in absorption values. It is evident that the electric field within the NRs is weakened as the pitch increases. Therefore, the weak coupling of the NRs to light originating from the weak confinement of the electric field within the nanorods results in the decrease of absorption. The simulated results indicate that as the distance increases, the electric field in air becomes weaker, which agrees well with the experimental results with respect to the confocal observation that the light field intensity around the nanorod changes with the distance of neighbouring nanorods. The top view electric field distributions at  $z = 120 \text{ nm}$  are depicted in Fig. S5.†

Since the internal resonance of the cylindrical nanostructures is mainly determined by diameters,<sup>20,29</sup> it is necessary to study the influences of diameters on the optical properties of the InGaN/GaN MQW NRs. The variations in absorption with diameters for NRs are depicted in Fig. 7(a). It is found that the absorption of NRs is almost 0 at the diameter of 50 nm. With the increase in the diameter, the absorption begins to rise sharply around  $D = 75 \text{ nm}$ , and a maximum value of 97.8% can be



**Fig. 6** (a) The absorption of InGaN/GaN MQW NRs at  $\lambda = 405 \text{ nm}$  with various pitches. (b)–(h) Electric field distributions of the nanorod arrays with different pitches.



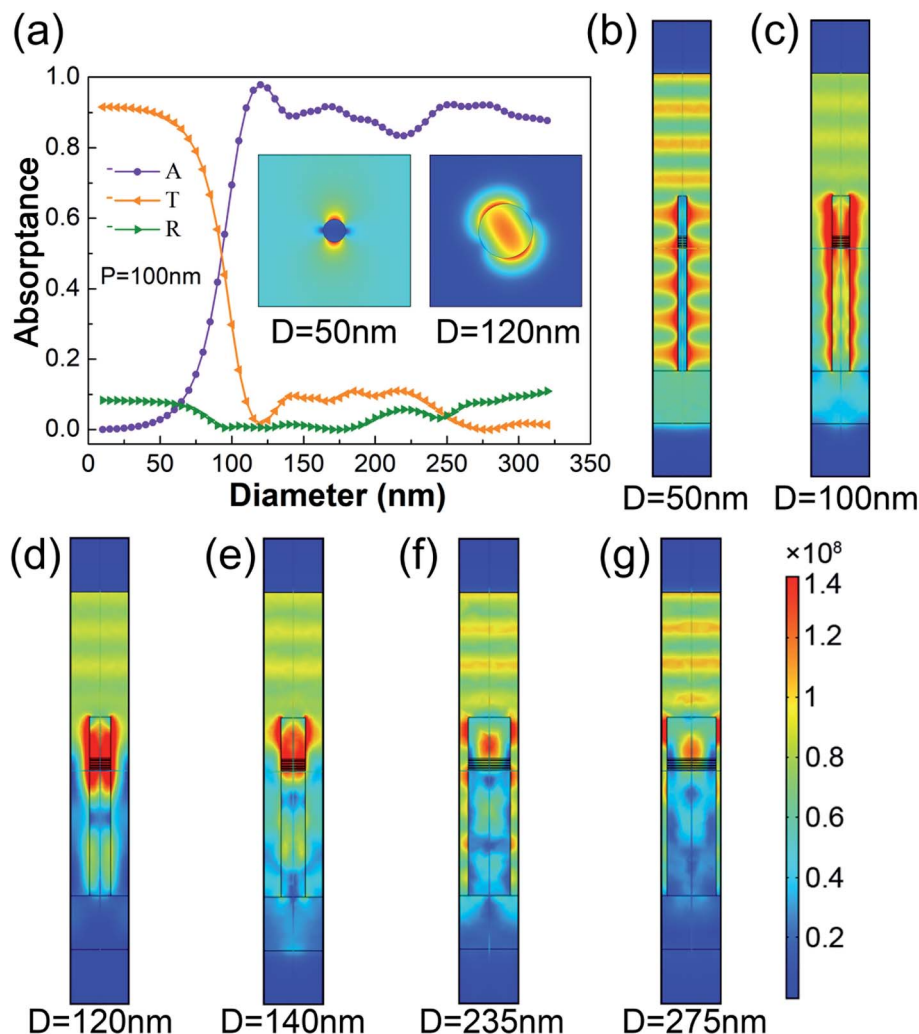


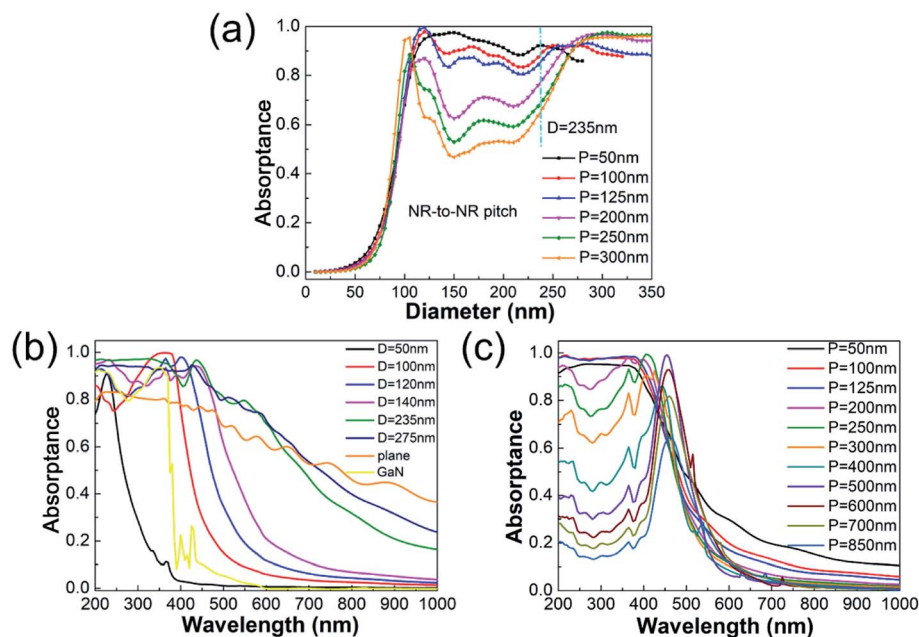
Fig. 7 (a)  $A(\lambda)$ ,  $T(\lambda)$  and  $R(\lambda)$  of InGaN/GaN MQW NR arrays with  $L = 1 \mu\text{m}$  and  $P = 100 \text{ nm}$  vary as a function of the NR diameter with incident plane wave of  $\lambda = 405 \text{ nm}$  corresponding to the experimental excitation light. (b)–(g) Cross-sectional distribution diagrams of the NR electric field with different diameters. The inset shows the electric field distributions of fundamental mode at two  $D = 50 \text{ nm}$  and  $120 \text{ nm}$ .

obtained at the diameter of 120 nm. However, the absorption decreases slightly as the diameter of the NRs continues to increase ( $>120 \text{ nm}$ ). The optical phenomenon can be explained by mode analysis and electric field distributions shown in Fig. 7(b)–(g). NRs with diameter that is much smaller than the ratio of the incident wavelength to the refractive index<sup>25</sup> hardly support any mode due to the effective refractive index close to 1. The modal electric fields shown in the inset indicate that NRs with  $D = 50 \text{ nm}$  and an effective refractive index of 1.02 cannot support fundamental mode, but the modal electric field can be well localized in the NRs with  $D = 120 \text{ nm}$ . Therefore, as shown in Fig. 7(b), the incident plane wave is guided outside the NRs and transmits almost without interference from the NRs, resulting in the light not being absorbed in the NRs. The value of the effective refractive index can be  $>1$  when the diameter of the NRs becomes larger, so that higher-order modes can appear in the NRs. As shown in Fig. 7(c)–(e), a larger electric field is obtained inside the NRs that induce the increase of absorption. The top view electric fields at  $z = 120 \text{ nm}$  are shown in Fig. S6.†

Fig. 8(a) shows the relationship between the NR absorption and diameters at different NR pitches. The trend in the variation of absorption related to the change in the diameter is almost independent from the NR-to-NR pitch. Apart from that the absorption of InGaN/GaN MQW NR arrays with  $P = 50 \text{ nm}$  and  $D = 125 \text{ nm}$  to  $250 \text{ nm}$  is higher due to the large fill factor. The higher absorption can be obtained at  $D = 120 \text{ nm}$  and  $P = 125 \text{ nm}$  (200 nm). We also simulated the absorption spectrum of GaN nanorod array with  $D = 120 \text{ nm}$  shown in Fig. 8(b). The results indicate that the wavelength at 355 nm contributes to the overall absorption of the GaN NRs because of good coupling of the incident light into the NRs. Fig. 8(b) illustrates the influences of NR diameter on the absorption spectrum. The results indicate that the absorption is the smallest for the diameter of 50 nm; nevertheless, the absorption of NR is higher than that of the plane MQW film due to enhanced light-matter interactions. It can be seen from the modal field in Fig. S7† that most light cannot be coupled into NRs with a small diameter, and more modes can be supported by increasing the diameter







**Fig. 8** (a) The diameter-dependent absorption varies with NR spacing at  $\lambda = 405$  nm. (b) The diameter-dependent absorption spectral curves of NR arrays with  $D$  ranging from 50 nm to 275 nm ( $P + D = 335$  nm), and the referential absorption spectrum of the plane InGaN/GaN MQW film. (c) The pitch-dependent absorption spectrum of NR arrays with  $D = 120$  nm.

of NRs, so the absorption increases greatly. In addition, the high-absorption region shifts to longer wavelengths, and the absorption peak position is red-shifted with the increase of diameter. Moreover, the oscillation of the simulated absorption curve is attributed to the Fabry–Perot resonance. The diameter of 120 nm for NR was fixed to investigate the effect of spacing on the absorption spectrum according to the simulated results shown in Fig. 8(a) and (b). Fig. 8(c) presents the absorption spectra of nanorod arrays with different periods. The calculated results reveal that the absorption peaks begin to broaden as the NRs approach each other due to the mutual coupling of the resonance modes of the neighbouring NRs with close distance. Therefore, the near-field coupling of the NRs would induce the increase of absorption. Besides, the absorption peak position exhibits a slight red shift with the increased distance. It also can be found that when the pitch is more than 500 nm, the absorption peak position remains constant with decreased absorption due to the weak coupling and small filling factor.

## Conclusion

In summary, the optical properties of InGaN/GaN MQW NRs fabricated by top-down dry etching with Ni nano masks are discussed experimentally and theoretically from a CLSM perspective. The geometric parameters of InGaN/GaN MQW NRs including diameter of 235 nm and length of 1.05  $\mu\text{m}$  are obtained. The In-content can be estimated to be 0.18 according to the peak position of the PL spectrum at room temperature. 3D images for understanding the interaction between light and nanostructures obtained by CLSM demonstrate that the NR geometry plays an important influence on its optical properties.

Therefore, the effects of NR geometric parameters on light-matter interactions in the  $\text{In}_{0.18}\text{Ga}_{0.82}\text{N}/\text{GaN}$  MQW NR arrays are investigated systematically by optical simulations. The simulated results indicate that the absorption of the NR exceeds that of the referential plane MQW film with the same structure due to its optical waveguiding properties. In agreement with the result of CLSM experiment, since the pitch of neighbouring NRs affects the near-field coupling and fill factor, the electric field of the NRs becomes stronger and the absorption increases with the decrease in the distance of neighbouring NRs at an excitation of  $\lambda = 405$  nm. It is also found that the absorption peak position shows a red-shift with the increase of NR diameter. Additionally, the pitch-dependent absorption spectra indicate that the absorption peak broadens owing to the enhanced near-field coupling of the neighbouring NRs. These results provide guiding suggestions for the design of InGaN/GaN MQW NR optoelectronic devices.

## Conflicts of interest

The authors declare no competing financial interest.

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